

PATENTS

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Nobuyuki ISHIWATA et al.

Serial No. 09/466,810

GROUP 2754

Filed December 20, 1999

Examiner

MAGNETORESISTANCE APPARATUS
HAVING REDUCED OVERLAPPING
OF PERMANENT MAGNET LAYER
AND METHOD FOR MANUFACTURING
THE SAME

CLAIM FOR FOREIGN PRIORITY UNDER 35 U.S.C. 119
AND SUBMISSION OF PRIORITY DOCUMENT

COPY

Commissioner of Patents

Washington, D.C. 20231

Sir:

Attached hereto is a certified copy of applicants' corresponding patent application filed in Japan on December 18, 1998, under No. 360159/1998.

Applicants herewith claim the benefit of the priority filing date of the above-identified application for the above-entitled U.S. application under the provisions of 35 U.S.C. 119.

Respectfully submitted,

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By

for

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November 30, 2000

日本国特許庁
PATENT OFFICE
JAPANESE GOVERNMENT

U.S.

別紙添付の書類に記載されている事項は下記の出願書類に記載されて
る事項と同一であることを証明する。

This is to certify that the annexed is a true copy of the following application as filed
in this Office.

出願年月日
Date of Application:

1998年12月18日

出願番号
Application Number:

平成10年特許願第360159号

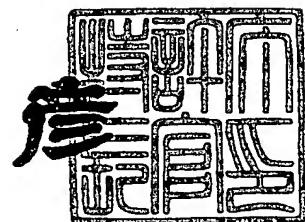
出願人
Applicant(s):

日本電気株式会社

1999年 9月24日

特許庁長官
Commissioner
Patent Office

近藤 隆



出証番号 出証特平11-306534